

## Raman studies of epitaxial multi-graphene films grown on a 6H-SiC substrates.

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Raman spectroscopy has historically been used to probe structural and electronic characteristics of graphite materials, providing useful information on the defects (D-band), in-plane vibration of  $sp^2$  carbon atoms (G-band), as well as the stacking orders (2D-band) [1]. This method fit also for quality examination of new carbon material – graphene. Raman spectra of graphite (graphene) may contain three strongest lines. Line *G* at  $\sim 1582\text{ cm}^{-1}$  derives from the doubly degenerate phonon mode of  $E_{2g}$  symmetry from the Brillouin zone center. Line *D* at  $\sim 1352\text{ cm}^{-1}$  appears in samples with high concentrations of structural defects and is associated with phonons close to the *K* point of Brillouin zone boundary. Line *2D* ( $\sim 2710\text{ cm}^{-1}$ ) originates from resonant light scattering involving two phonons of equal energy but with oppositely directed wave vectors, and provides information on the stacking order of graphite (graphene) layers.

The micro-Raman studies were performed in back-scattering geometry  $y(xx)\bar{y}$  on a Horiba Jobin-Yvon T64000 spectrometer by means of a confocal microscope at room temperature. The spectra were excited with an Ar<sup>+</sup> laser ( $\lambda = 514.5\text{ nm}$ ). To exclude local heating effects, which could result in a shift of phonon lines, the laser radiation power on the sample was  $<1\text{ mW}$  (diameter of the laser beam was  $4\text{ }\mu\text{m}$ ).

For investigations multi-graphene layers on 6H-SiC substrates were used. Graphene films were grown on silicone carbide by sublimation method [2]. We used samples grown in the temperature range of  $1300\text{-}1600^\circ\text{C}$  to examine the quality of multi-graphene films from growth temperature.

Raman spectra of samples grown at low temperatures ( $1300\text{-}1400^\circ\text{C}$ ) exhibit strong line *D*, which indicate the presence of defects, whereas spectra of samples grown at high temperatures ( $1500\text{-}1600^\circ\text{C}$ ) don't exhibit *D*-line.

Thus Raman investigations show that the multi-graphene films grown at low temperatures are much more defective than the films grown at high temperatures.

- [1] M.A. Pimenta, G. Dresselhaus, M.S. Dresselhaus; L.G. Cancado, A. Jorio, R. Saito, *Phys. Chem. Chem. Phys.* **9**, 1276 (2007).
- [2] A.A. Lebedev, I.S. Kotousova, A.V. Lavrentiev, S.P. Lebedev, I.V. Makarenko, V.N. Petrov, A.N. Titkov, *Phys. Solid State* **51**(4) (2010).